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1030nm, 0.80 NA, aplanoXX Aplan Objective | aplanoXX NA0.8_20_1030

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AdlOptica aplanoXXAplan Objectives



Stock **#19-491** **2 In Stock**

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1

+

£6,869⁰⁰

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Qty 1+	£6,869.00 each
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Product Downloads

General	
aplanoXX NA0.8_20_1030	Model Number:
Objective	Type:

±0.3	Field of View (°):
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Note:
Includes aplanoXX objective, mounted protective window (#19-495), and spanner wrench (#19-497)

Physical & Mechanical Properties

54.10	Length (mm):
20	Clear Aperture CA (mm):
44.00	Diameter (mm):

Optical Properties

12.50	Focal Length FL (mm):
0.80	Numerical Aperture NA:
2.5 (1.6 with Protective Window)	Working Distance (mm):
1030	Design Wavelength DWL (nm):
1020 - 1100	Wavelength Range (nm):
100 mJ @ 5ns 300 μJ @ 1ps	Damage Threshold, By Design: □
0 - 4	Focusing Depth (mm):
20 (maximum)	Beam Diameter (mm):
100 mJ @ 5ns 300 μJ @ 1ps	Damage Threshold, Pulsed:

Threading & Mounting

C-Mount	Mount:
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Regulatory Compliance

Compliant	RoHS 2015:
View	Certificate of Conformance:
Compliant	Reach 250:

Product Details

- Aplanatic Optical Design
- High Numerical Aperture for Small Spot Sizes
- Designs for 800 and 1030nm with Focusing Depth Up to 4mm
- AdlOptica foXXus Multi-Focus Objectives Also Available

AdlOptica aplanoXX Aplan Objectives compensate for spherical aberration and coma when focusing into glass, sapphire, silicon carbide, silicon, PMMA and other transparent materials at depths up to 4mm. These objectives are designed to be used with ultrafast solid-state and fiber lasers and are optimized for 800nm (Ti:sapphire) and 1030nm (Yb:doped). Featuring C-Mount threading and an optical design insensitive to misalignment, these objectives are easy to integrate into laser systems. AdlOptica aplanoXX Aplan Objectives are ideal for micromachining glass, 3D nanofabrication, waveguide recording, and selective laser etching. A collar on the objective allows for manual adjustment of focus and a replaceable front window protects from debris during materials processing.

Technical Information

